

A1
end
2nd
B1
C1

forming a data line, a source electrode and a drain electrode on the active layer;
forming a passivation layer on the gate-insulating layer, the passivation layer covering the data line, source electrode and drain electrode;
dry-etching a surface of the passivation layer with a gas without using a photo mask such that the surface is embossed; and
forming a reflective electrode on the embossed surface of the passivation layer such that an exterior surface of the reflective electrode is embossed.

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11. (Amended) A liquid crystal display device comprising:

2nd
B2
A2

upper and lower substrates with a liquid crystal layer interposed therebetween;
a gate line and a gate electrode on the lower substrate;
a gate-insulating layer on the lower substrate, the gate-insulating layer covering the gate line and gate electrode;
an active layer on the gate-insulating layer;
a source electrode and a drain electrode on the active layer;
a data line on the gate-insulating layer;
a passivation layer on the data line, source electrode, and drain electrode, an entire surface of the passivation layer being embossed; and
an embossed reflective electrode on the passivation layer.